

DPW



PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of:
HARUHITO ONO ET AL. : Examiner: J.D. Lee
Application No.: 10/615,955 : Group Art Unit: 2874
Filed: July 10, 2003 :
For: MULTI-CHARGED BEAM LENS,)
CHARGED-PARTICLE BEAM :
EXPOSURE APPARATUS)
USING THE SAME, AND :
DEVICE MANUFACTURING)
METHOD : April 18, 2005

MAIL STOP
Commissioner for Patents
PO Box 1450
Alexandria, VA 22313-1450

RESPONSE TO RESTRICTION REQUIREMENT

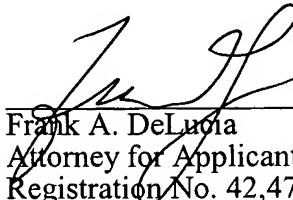
Sir:

In response to the Office Action dated March 25, 2005, Applicants elect, without traverse, to proceed initially with examination of Group I (Claims 1-19).

Applicants respectfully request favorable consideration on the merits and early passage to issue of the elected claims.

Applicants' undersigned attorney may be reached in our New York office by telephone at (212) 218-2100. All correspondence should continue to be directed to our below listed address.

Respectfully submitted,



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Registration No. 42,476

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